

Surface engineering by ALD and heat treatment for 3D Niobium resonators for applications in superconducting qubits

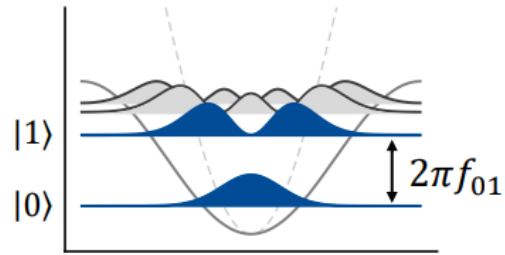
Y. Kalboussi¹, B. Delatte¹, M. Benko¹, I. Curci¹, T. Dejob¹, S. Bira^{2,3}, D. Longuevergne³, T. P Donat³, F. Miserque⁴, S. Tusseau-Nenez⁵, Y. Zheng⁶, D. Drago⁷, D. Bafia⁸, L. Grasselino⁸, G. Ereemeev⁸, F. Crisa⁸, A. Gentils⁹, S. Jublot Leclerc⁹, X. Li¹⁰, M. Walls¹⁰, N. Brun¹⁰, K. Dembele¹¹, J.L Maurice¹¹, T. Proslir¹

¹IRFU, CEA Paris-Saclay University, Paris, France; ²Jefferson laboratory; ³IJCLab, CNRS, Paris-Saclay University, ⁴LECA, CEA Paris-Saclay University, Paris, France; ⁵Plateforme DIFFRAX, Ecole Polytechnique; ⁶INSP, CNRS, Sorbonne University; ⁷Plateforme ICMO, Paris-Saclay University. ⁸DES, CEA Paris Saclay University, ⁸Fermi National Accelerator Laboratory, USA. ⁹Plateforme MOSAIC, IJCLab Paris-Saclay University, ¹⁰LPS, CNRS, Paris-saclay University. ¹¹Plateforme CIMEX, Ecole Polytechnique.



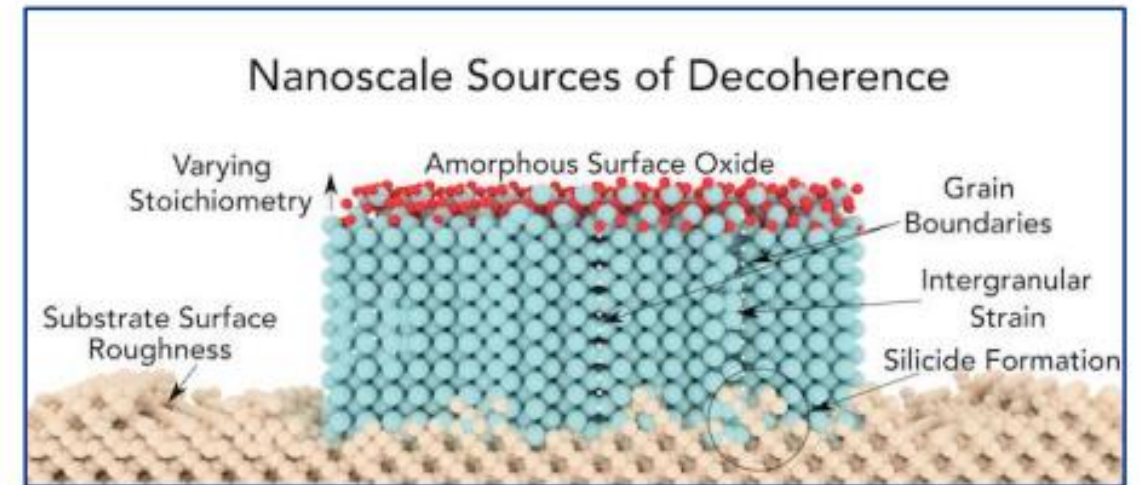
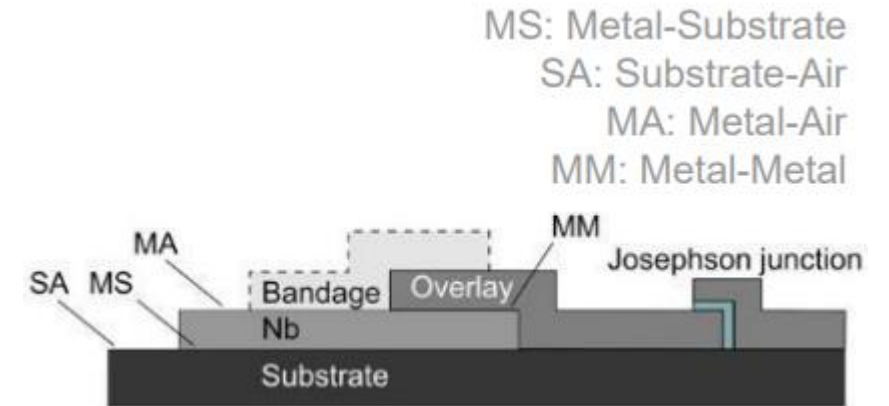
Context: Superconducting Qubits

Strongly anharmonic oscillator
(qubit)

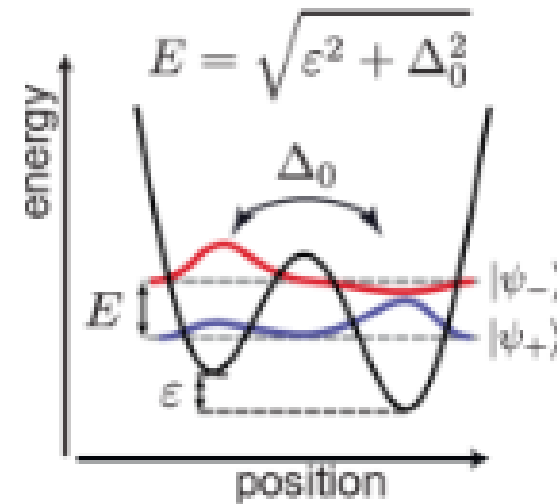
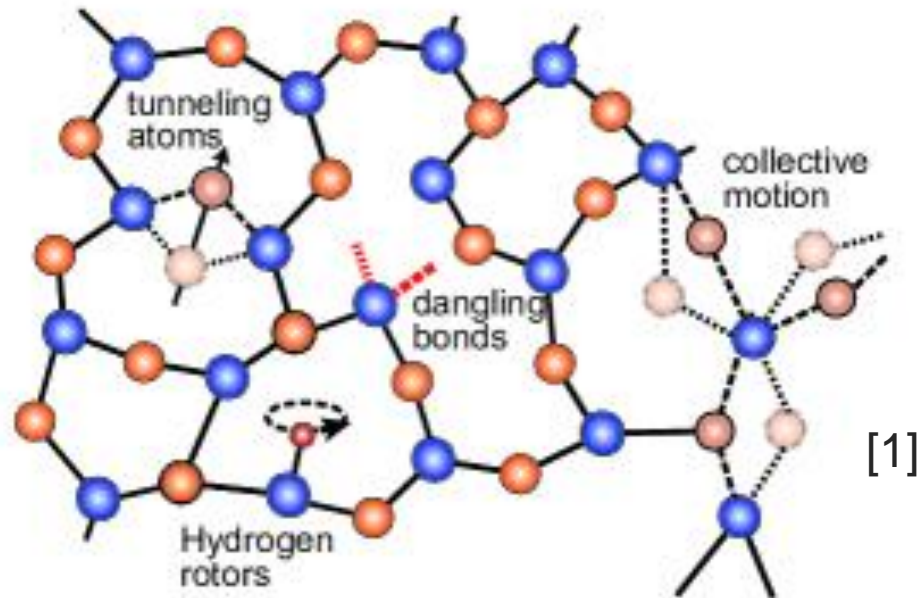


$$|\psi\rangle = \cos(\theta) |0\rangle + e^{i\varphi} \sin(\theta) |1\rangle$$

- 2D superconducting qubits suffer from limited coherence times (at best $T_1 \sim 200\mu\text{s}$.)
- Defects in the oxides layers are the major source of decoherence.



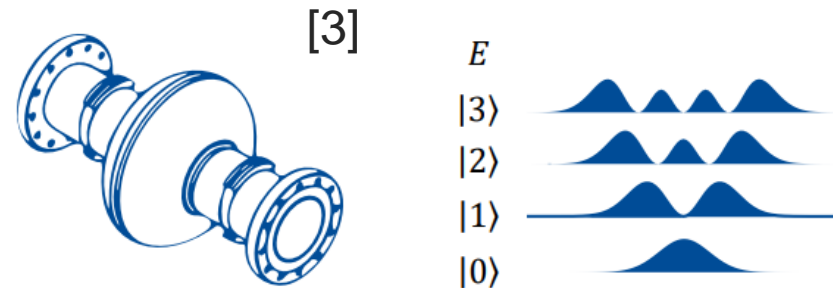
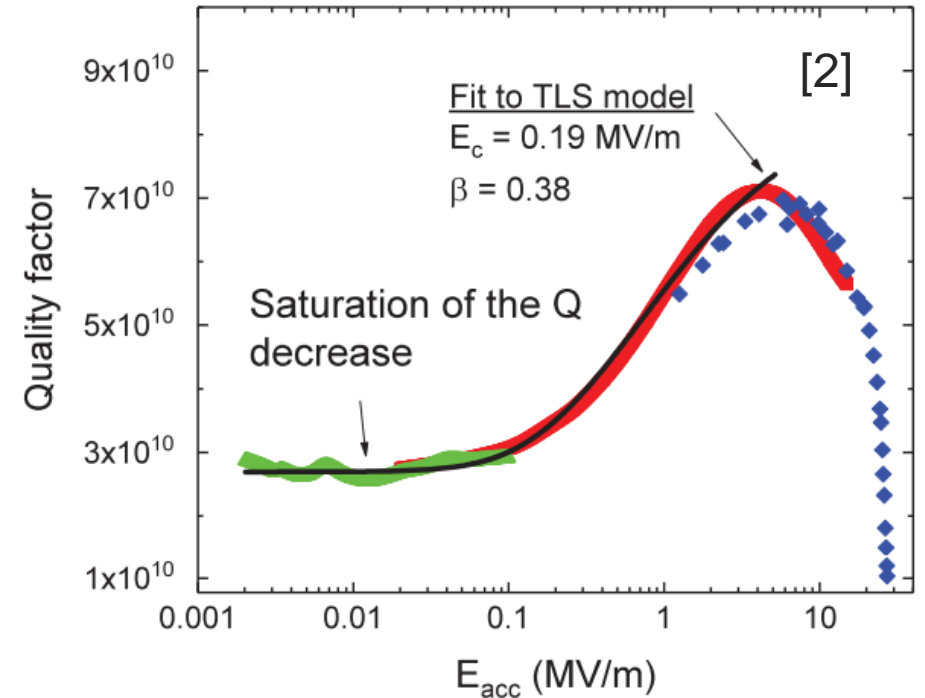
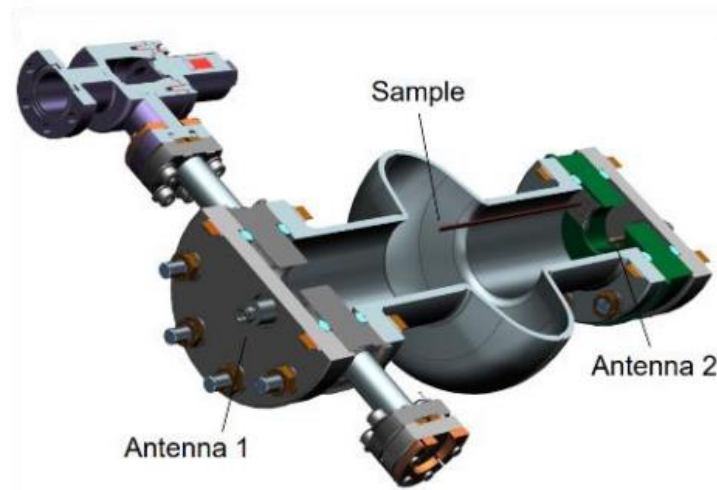
Two-level system defects in amorphous materials



- Their microscopic nature is still elusive:
- It can be tunneling atoms, tunneling electrons or spins and magnetic impurities.
- The TLS can exist in one of two energetically similar configurations
- At High temperature and high RF intensities, these defects are saturated.
- At low temperature, TLS couples to the electric field present in the qubit and causes decoherence.

SRF cavities are excellent tools to advance quantum computing

1. As a tool to study materials : SRF cavities exhibit the same dielectric losses at low fields.
2. As multi-level quantum bits : Tesla cavities are being integrated in quantum processing units.

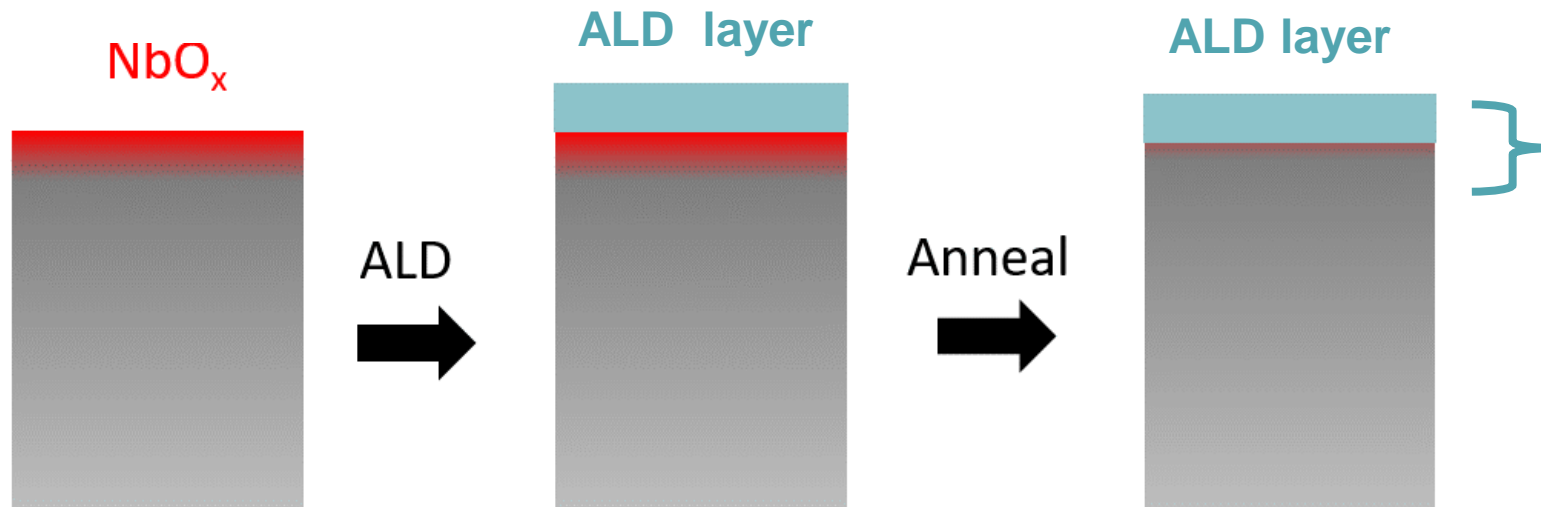


$$|\psi\rangle = c_1|0\rangle + c_2|1\rangle + \dots + c_n|n\rangle$$

The passivation approach at CEA:

To replace niobium native oxides with ALD-deposited protective layer [1]

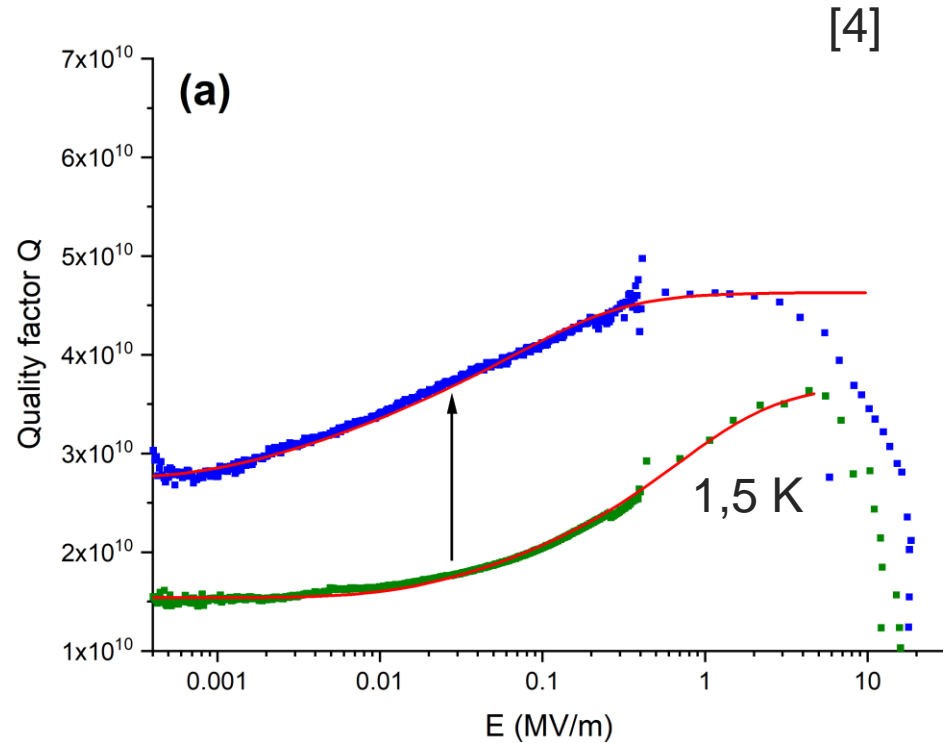
- 1) Deposit ~few nm oxide layer by ALD (Al_2O_3 , Ta_2O_5 , ZrO_2 ...) onto Niobium.
- 2) Perform a subsequent thermal treatment to dissolve niobium native oxide underneath (vacuum levels 10^{-6} mbar)



First results at CEA :

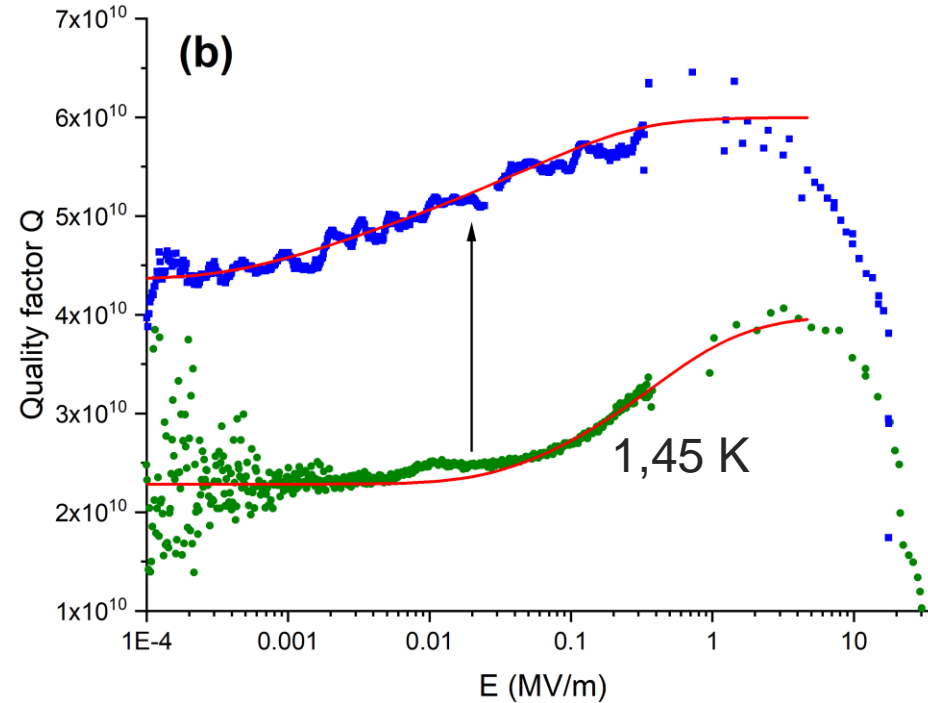
First experiment

Al₂O₃-10nm- 650°C- 4hrs



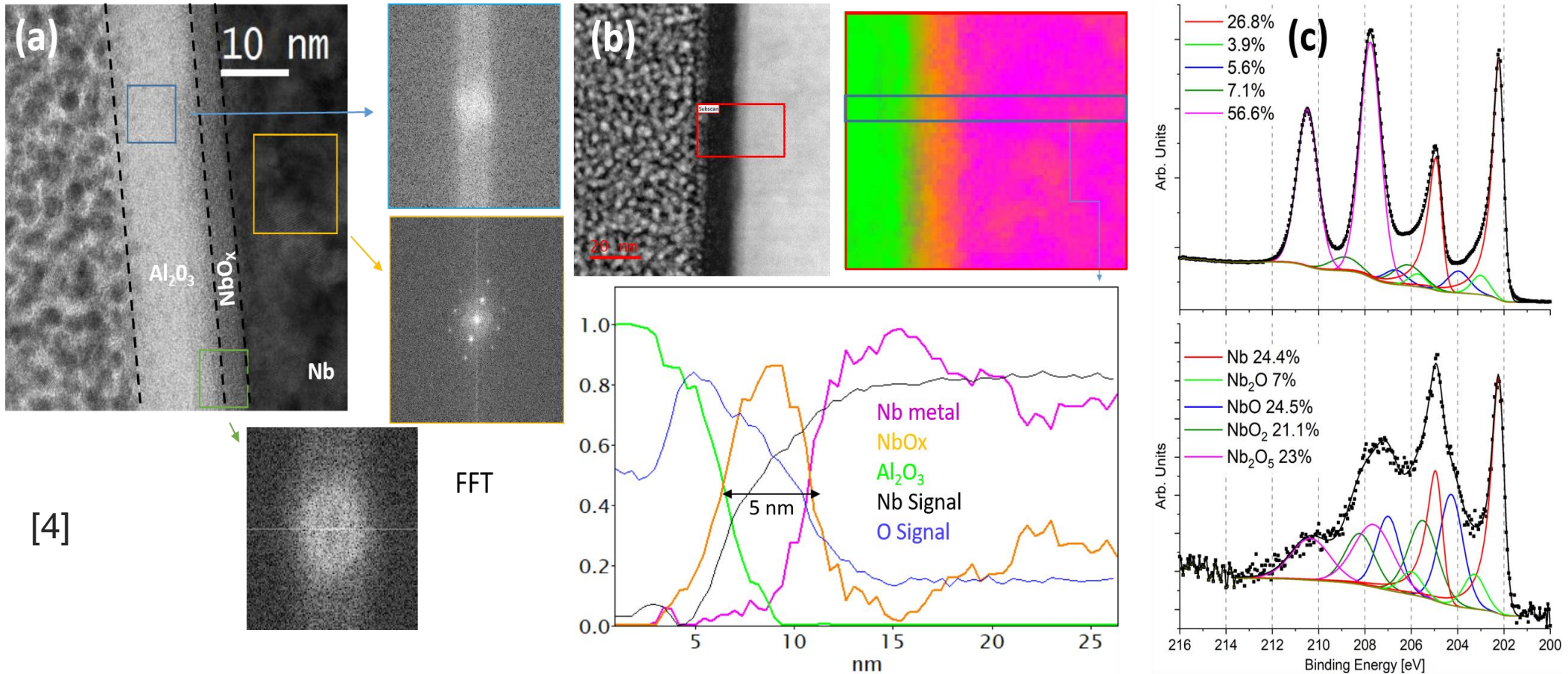
Second experiment

Al₂O₃-10nm- 650°C- 10hrs



- The 10 nm Al₂O₃ film + annealing at 650°C for few hours significantly improves the quality factors of the Nb cavity in the low field regime.

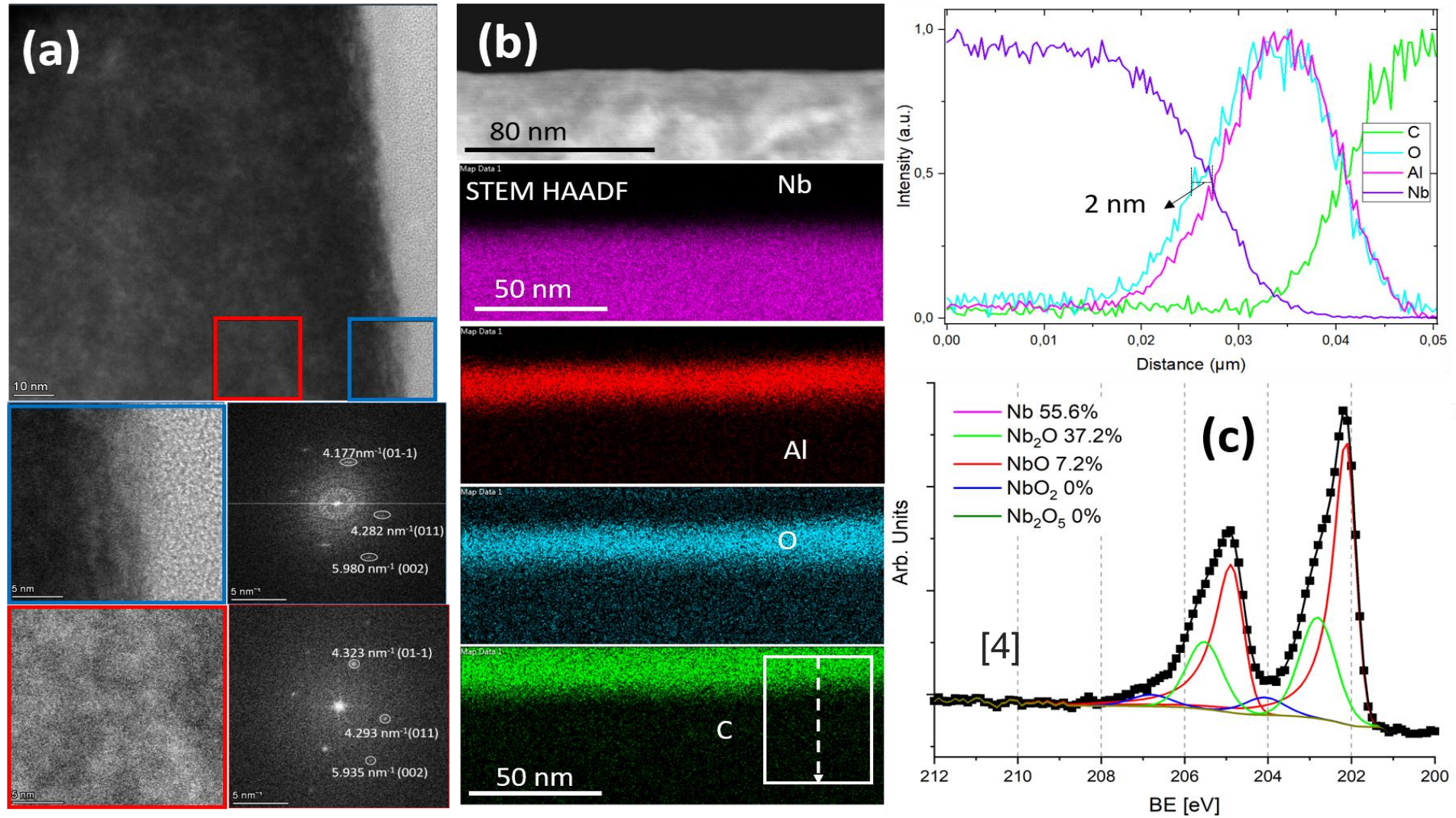
Before Annealing :



[4]

- Before annealing, we have 5 nm of Nb oxide between the Al_2O_3 and the Nb metal.

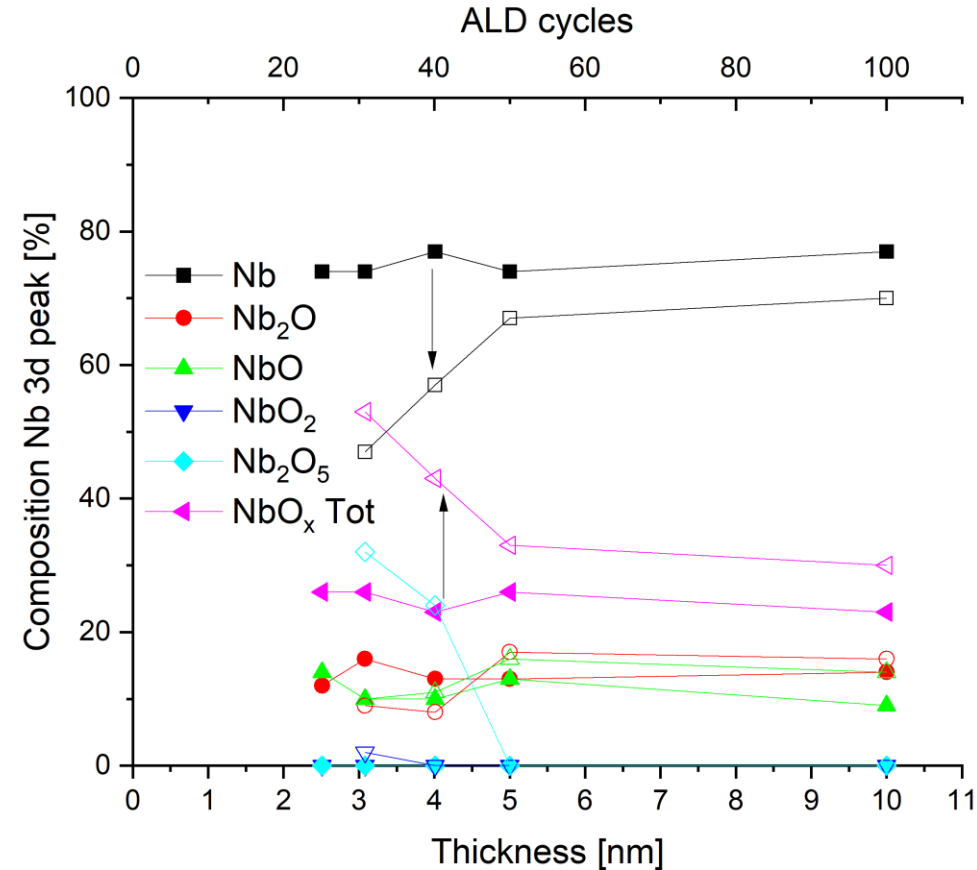
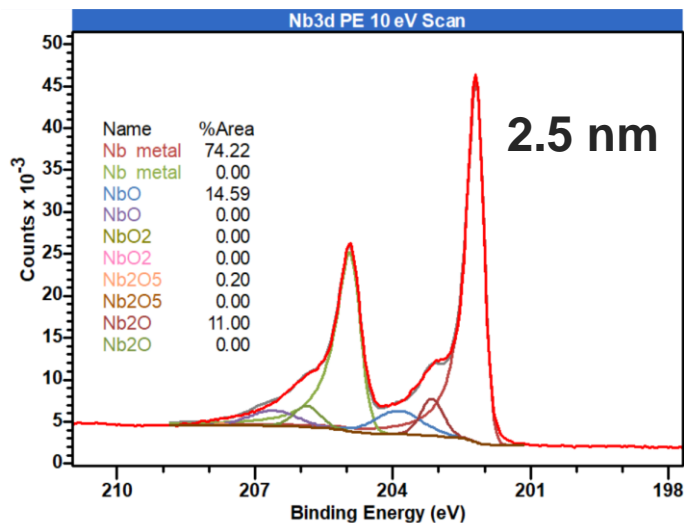
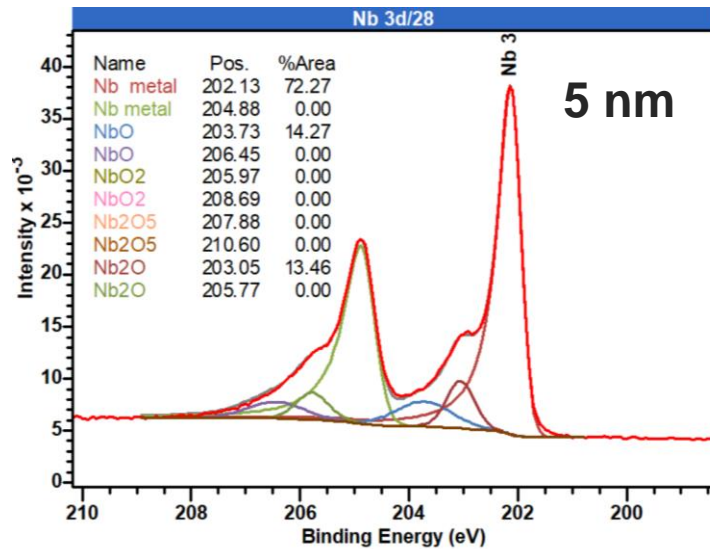
After Annealing



- After annealing, we have 2 nm of Nb oxide, mainly NbO and Nb₂O. No Nb₂O₅.
- The interface is crystalline with the bulk Nb.

Al₂O₃ hosts TLS too ...

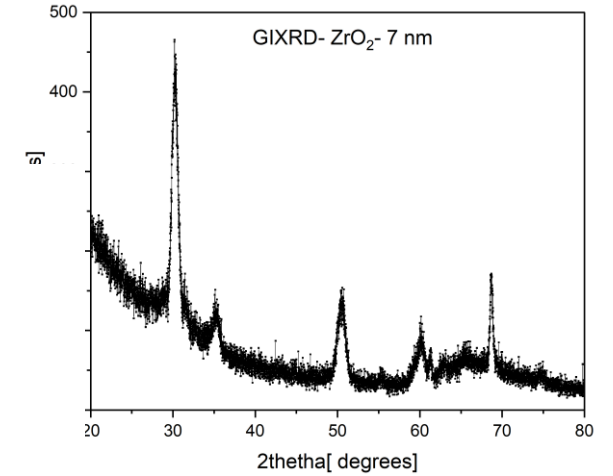
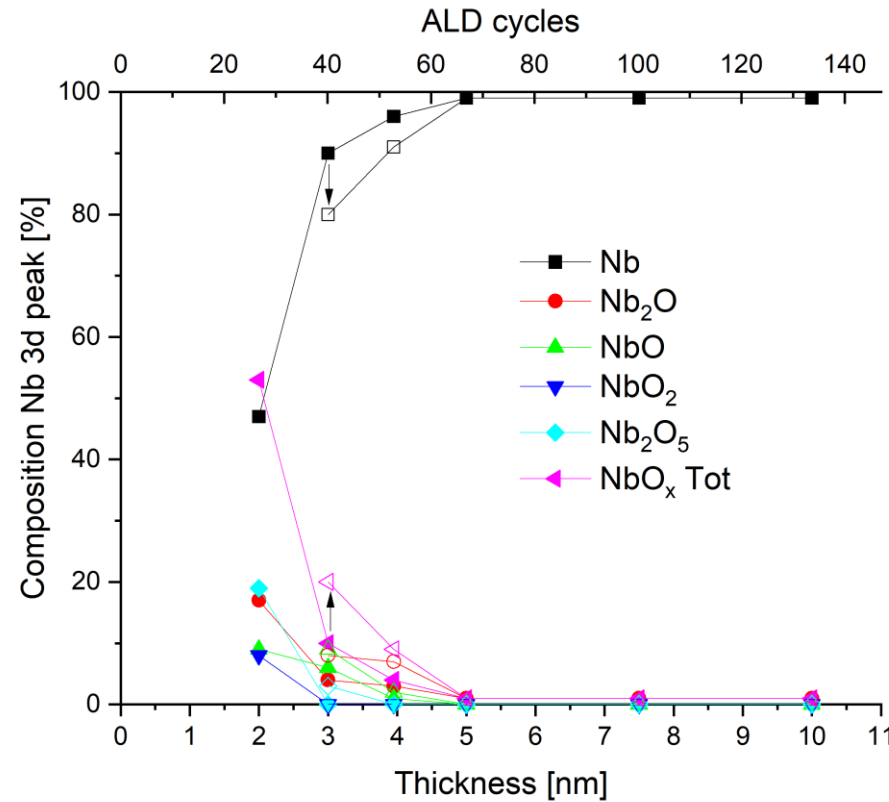
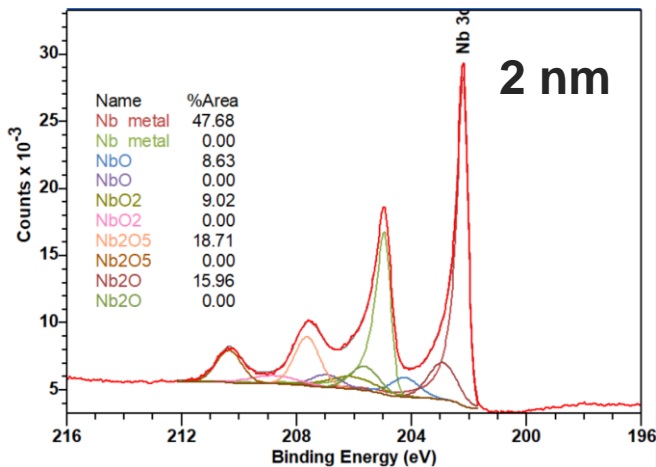
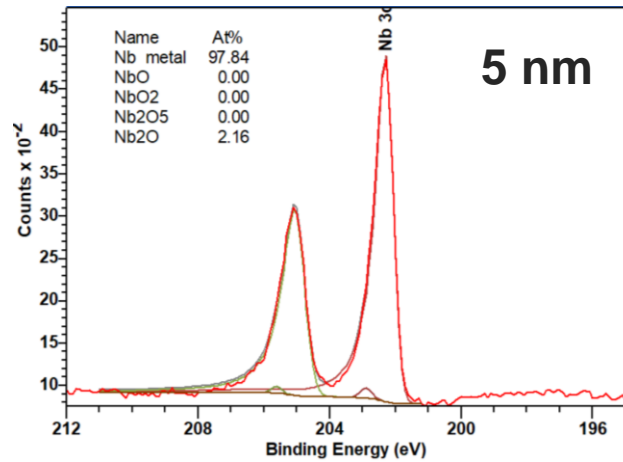
- We tested different thickness of Al₂O₃ + Annealing @650°C+10 hours



- The Nb remains passivated even with only 2,5 nm of Al₂O₃
- After HPR, we need at least 5 nm to protect the Nb surface.

A crystalline oxyde: ZrO_2

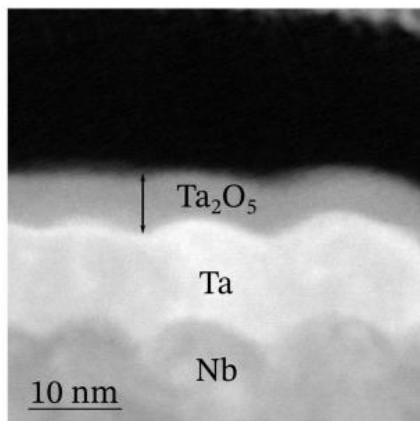
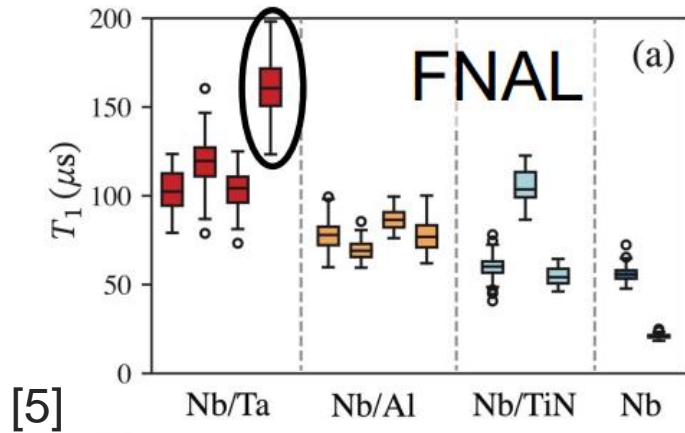
- We tested different thickness of ZrO_2 on Nb + Annealing $800^\circ C - 3hrs$



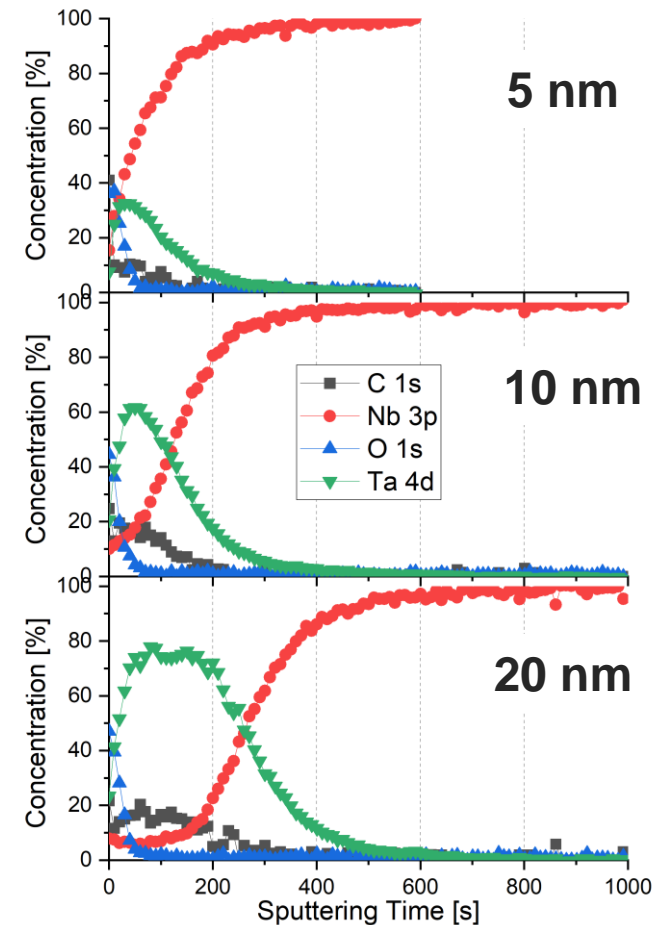
- We need at least 5 nm of ZrO_2 to passivate efficiently Nb.

Another candidate: Ta_2O_5

- Tantalum oxide results in lower losses than niobium oxide:
- Possibly due to consistency in Ta^{5+} valence state and low vacancy concentration.

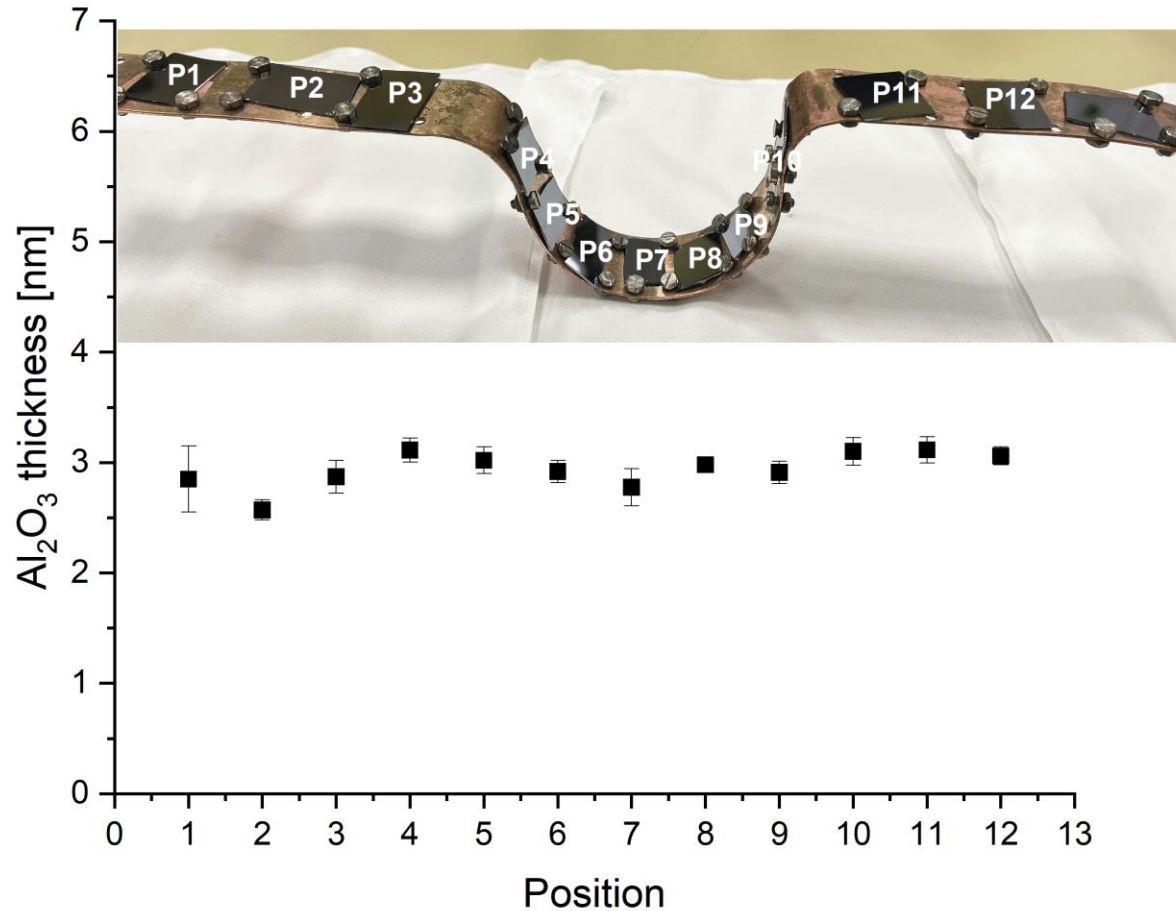


Annealed at 900°C-3hrs



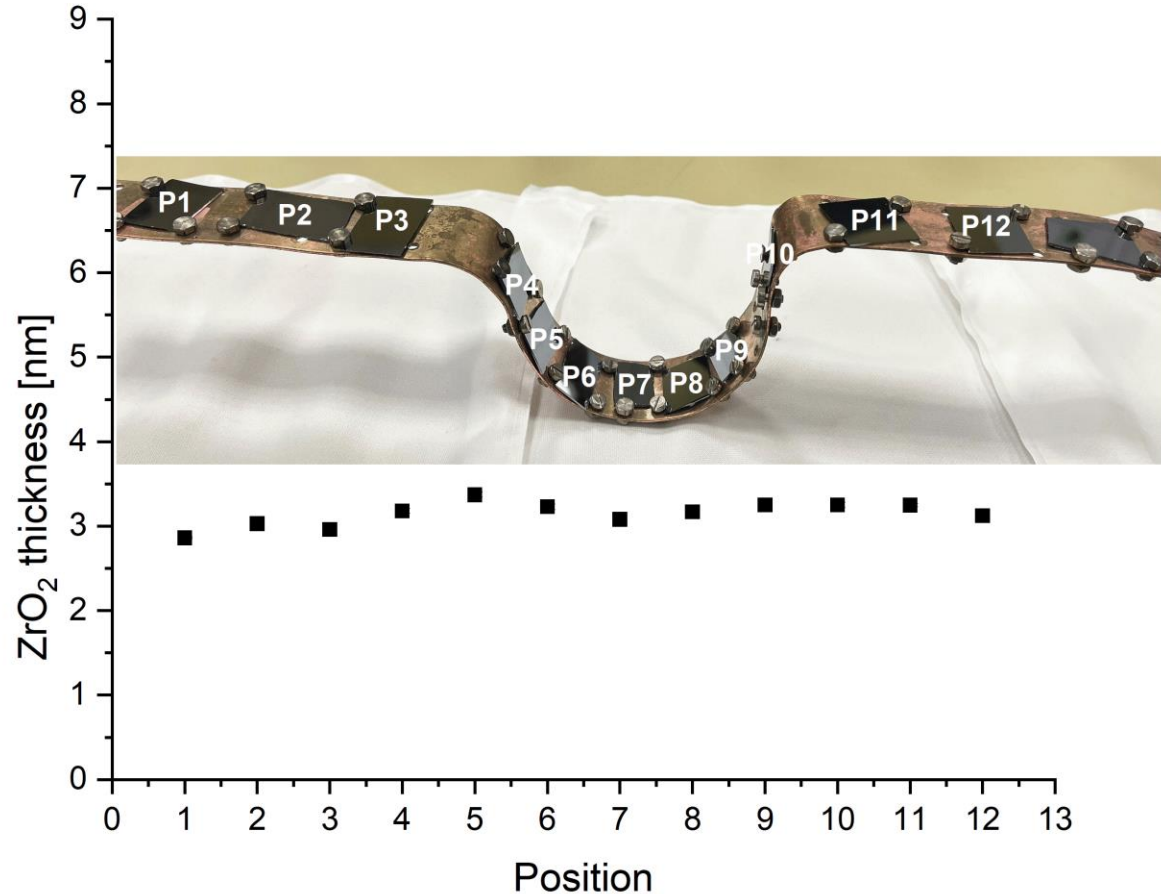
- We observe intermixing between Tantalum and Niobium.
- Optimization is ongoing in collaboration with FNAL.

Thickness homogeneity of Al_2O_3 test on 1.3 GHz



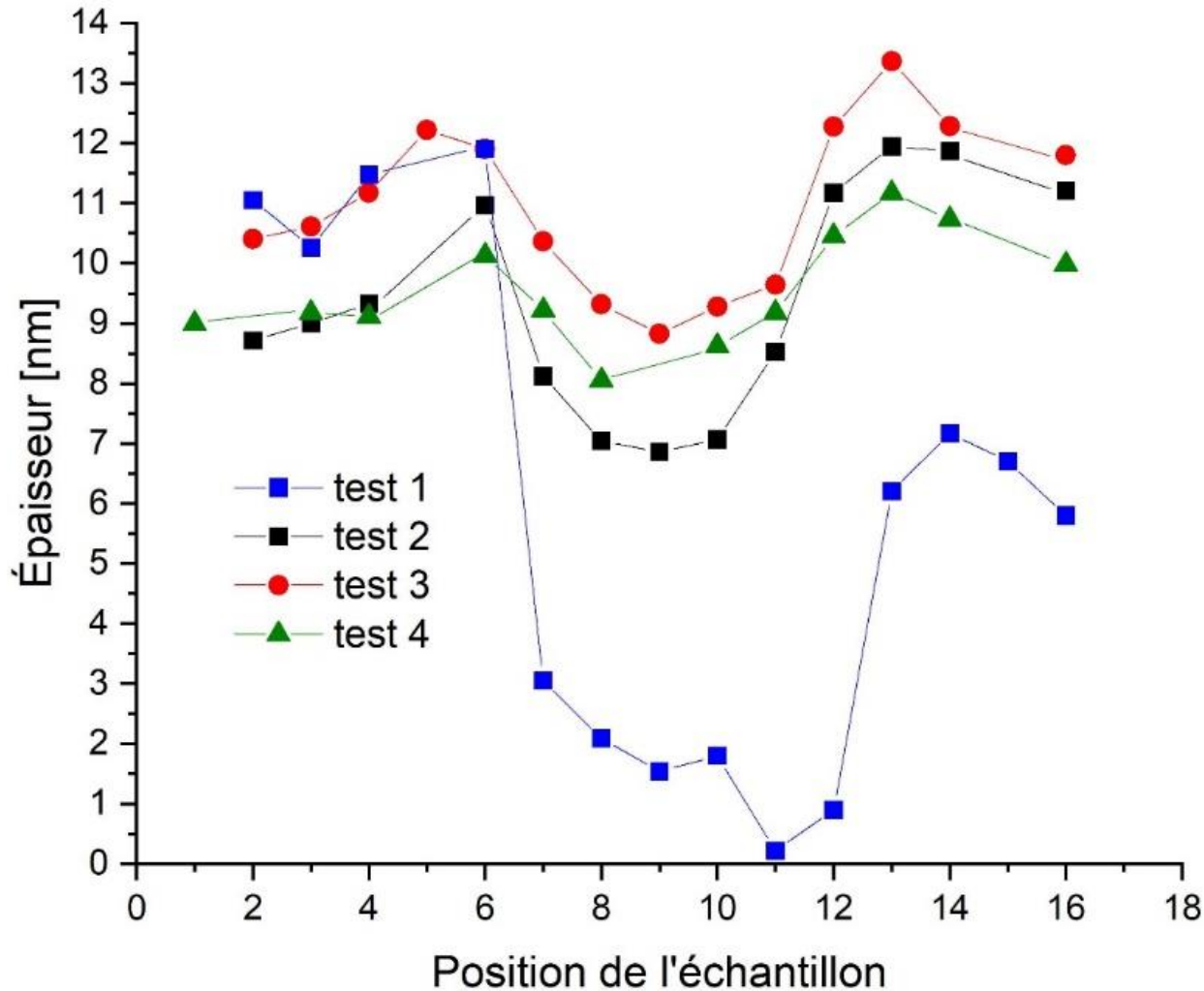
- We performed homogeneity test of 2,5 nm of Al_2O_3 inside a 1,3 Ghz cavity.
- The precursors are TMA and H_2O at 250°C .
- We coated Two 1,3 Ghz Nb cavities and we are waiting for them to be tested one at CEA and one at FNAL.

Thickness homogeneity of ZrO_2 test on 1.3 GHz



- We performed homogeneity test of 3 nm of ZrO_2 inside a 1,3 Ghz cavity.
- The precursors are $Zr(NMe_2)_4$ and H_2O at $200^\circ C$.
- We coated one 1,3 Ghz Nb cavity and we are waiting for the RF test at FNAL.

Thickness homogeneity of Ta₂O₅ test on 1.3 GHz

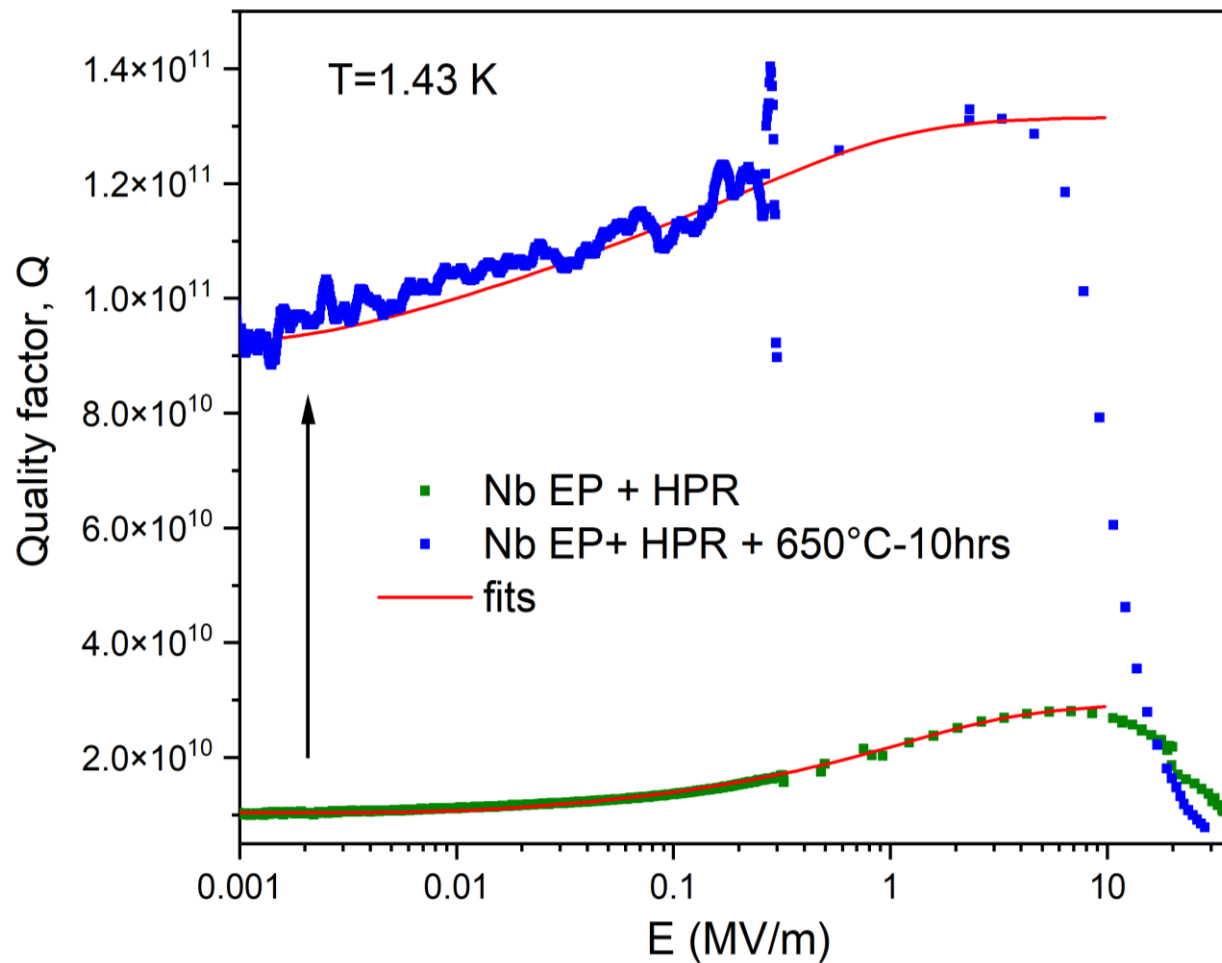


□ ALD recipe:
Ta(OC₂H₅)₅ and H₂O at 250°C

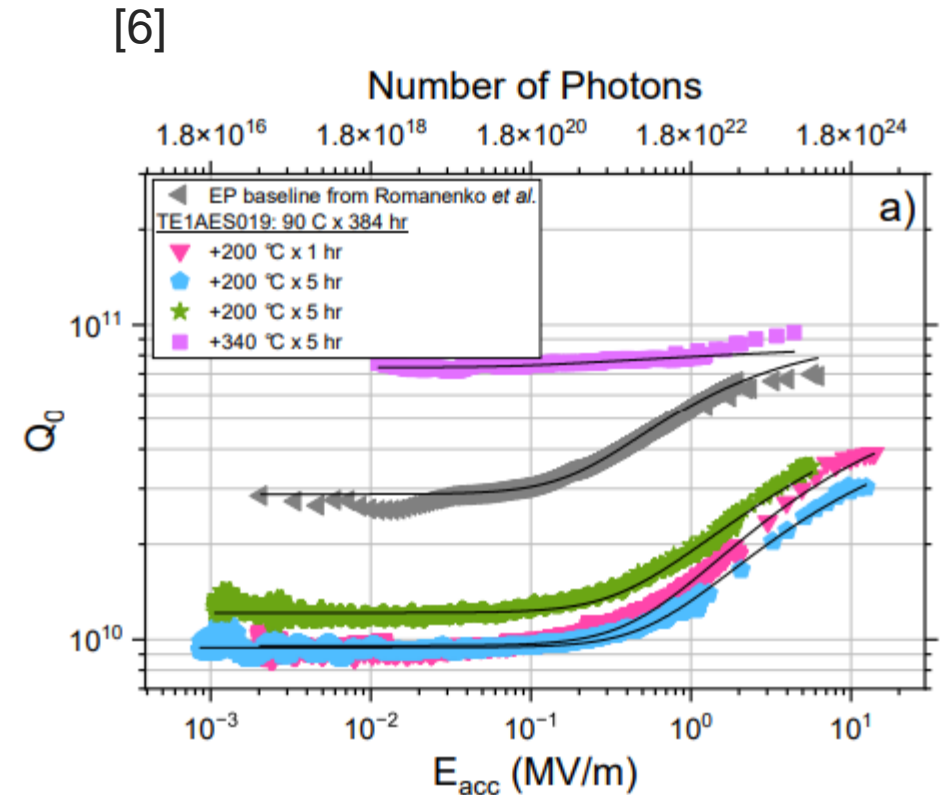
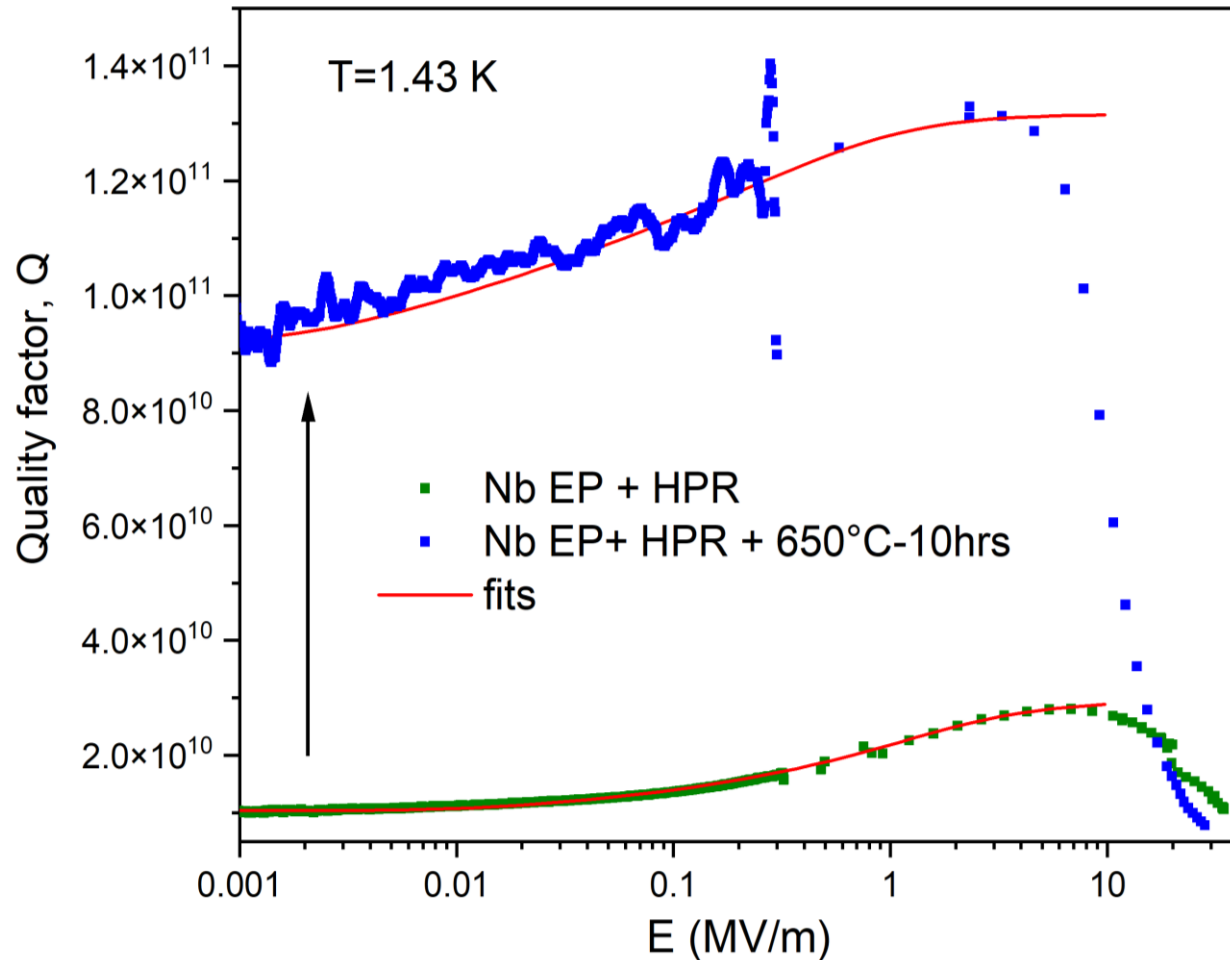
Test1: 1,5s / 20s / 1,5s / 15s
Test2: 2,5s / 20s / 1,5s / 15s
Test3: 3s / 60s / 1,5s / 15s
Test4: 3s / 60s / 1,5s / 60s

□ We coated one 1,3 Ghz Nb cavity and we are waiting for the RF test at FNAL.

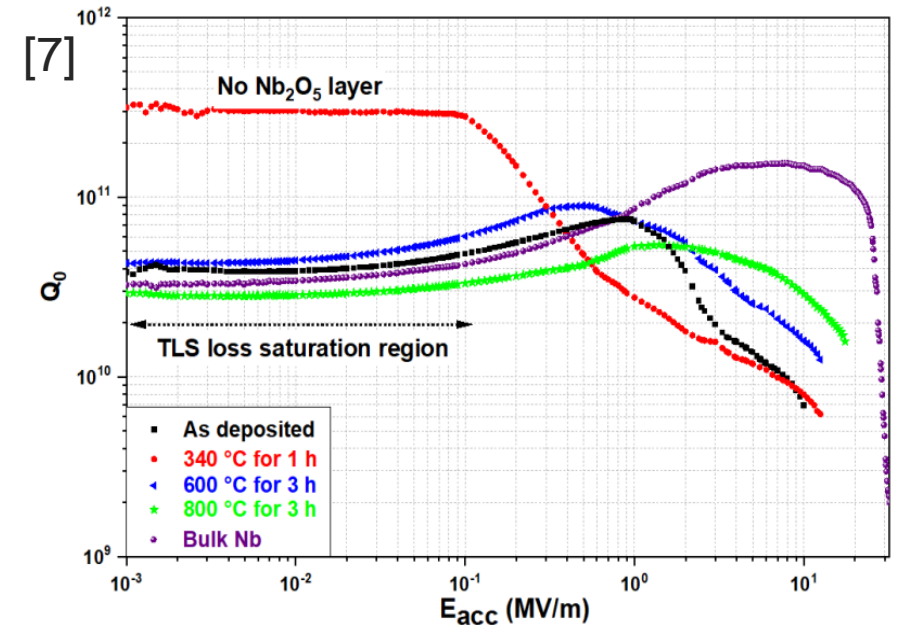
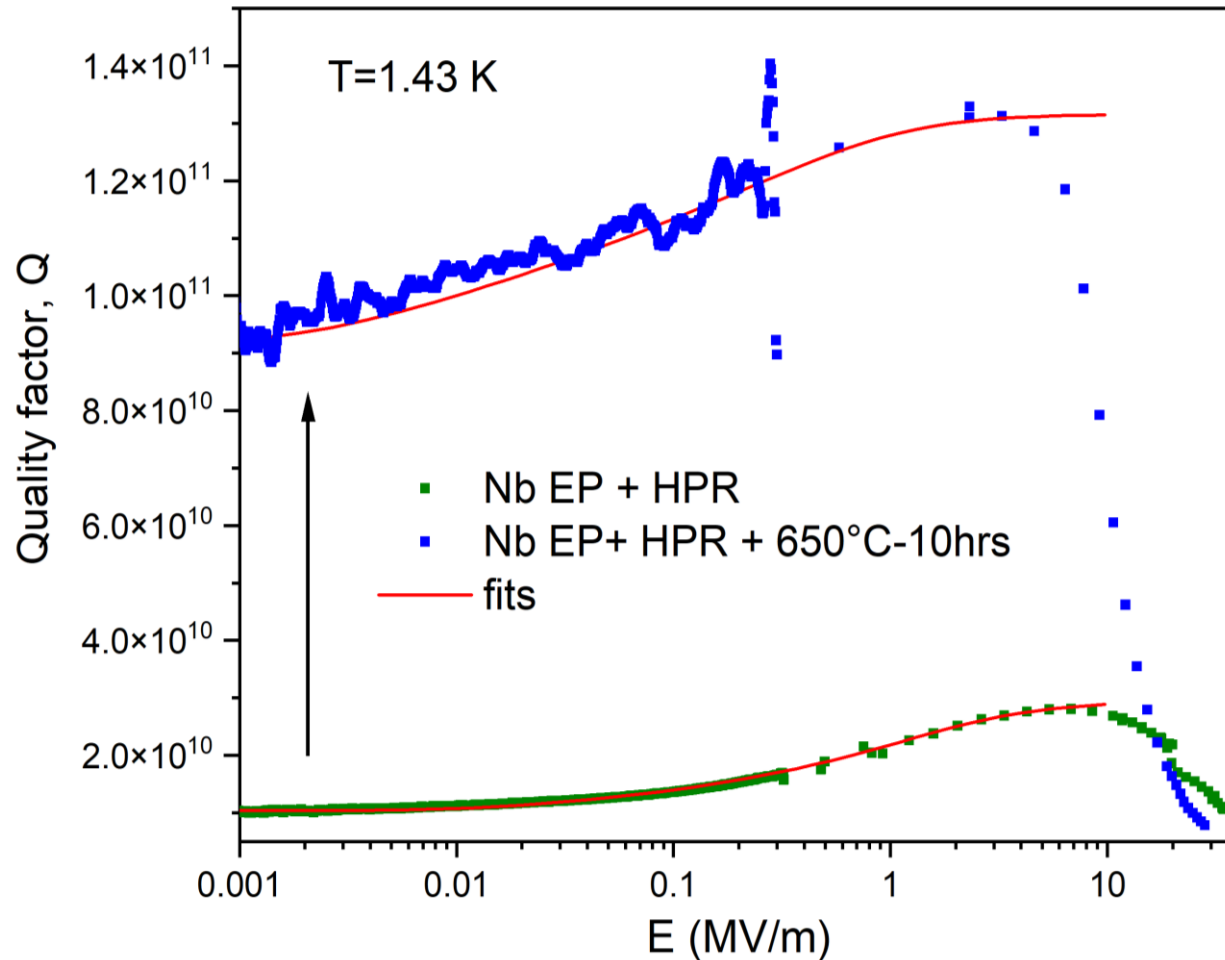
The highest coherence time ever measured on Air exposed Nb: $T_1 = 17$ s at 1.4 K



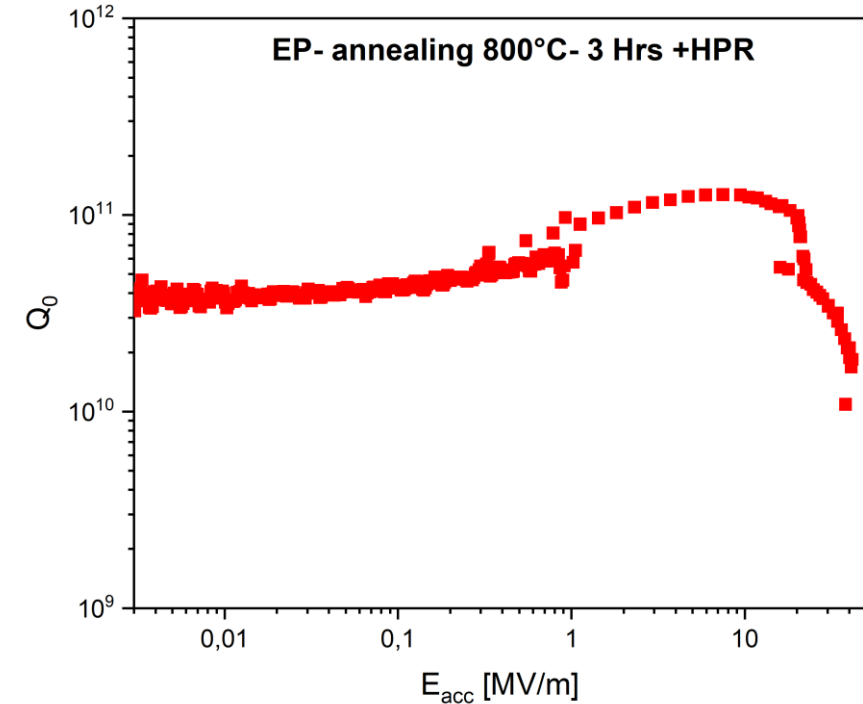
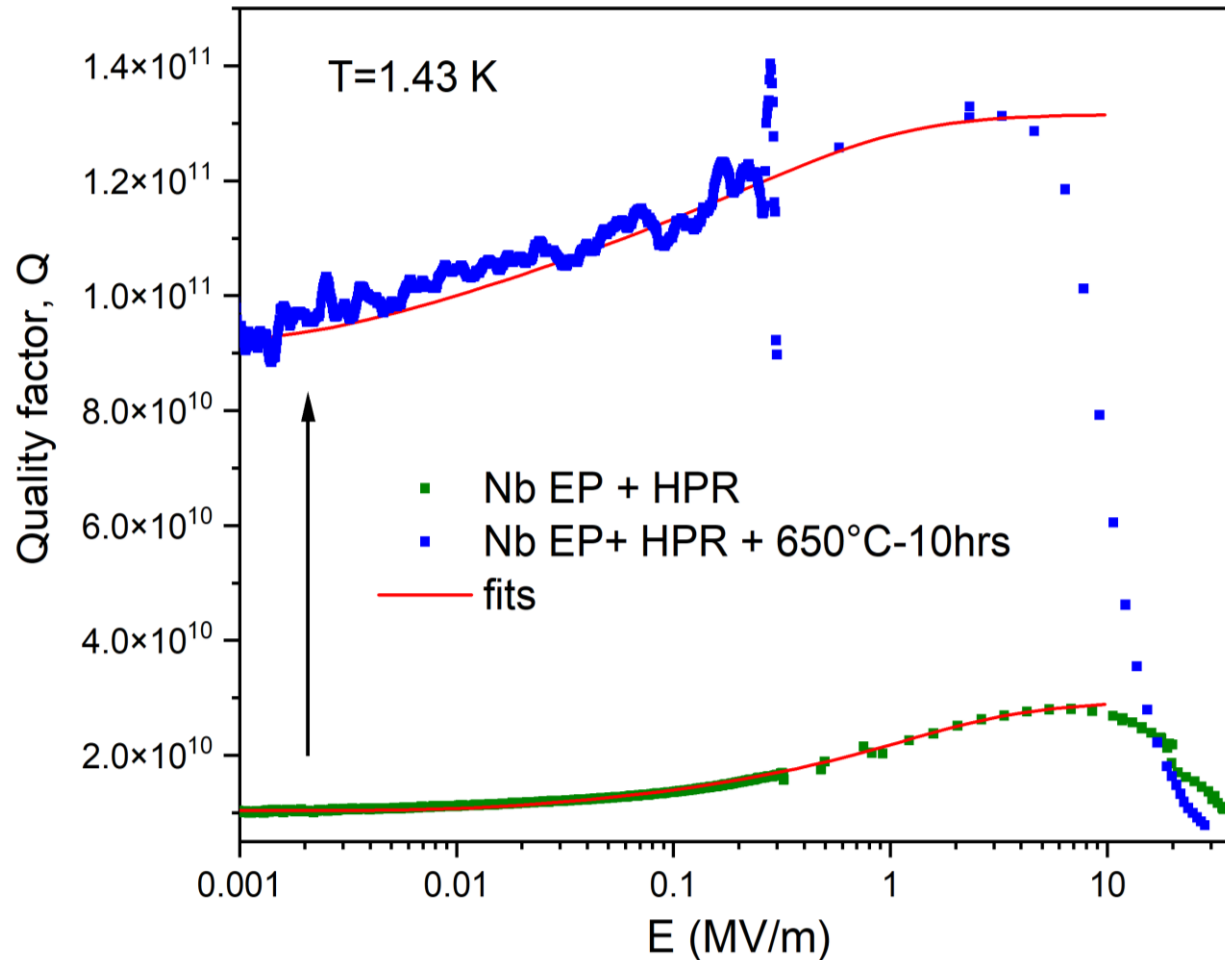
The highest coherence time ever measured on Air exposed Nb: $T_1 = 17$ s at 1.4 K



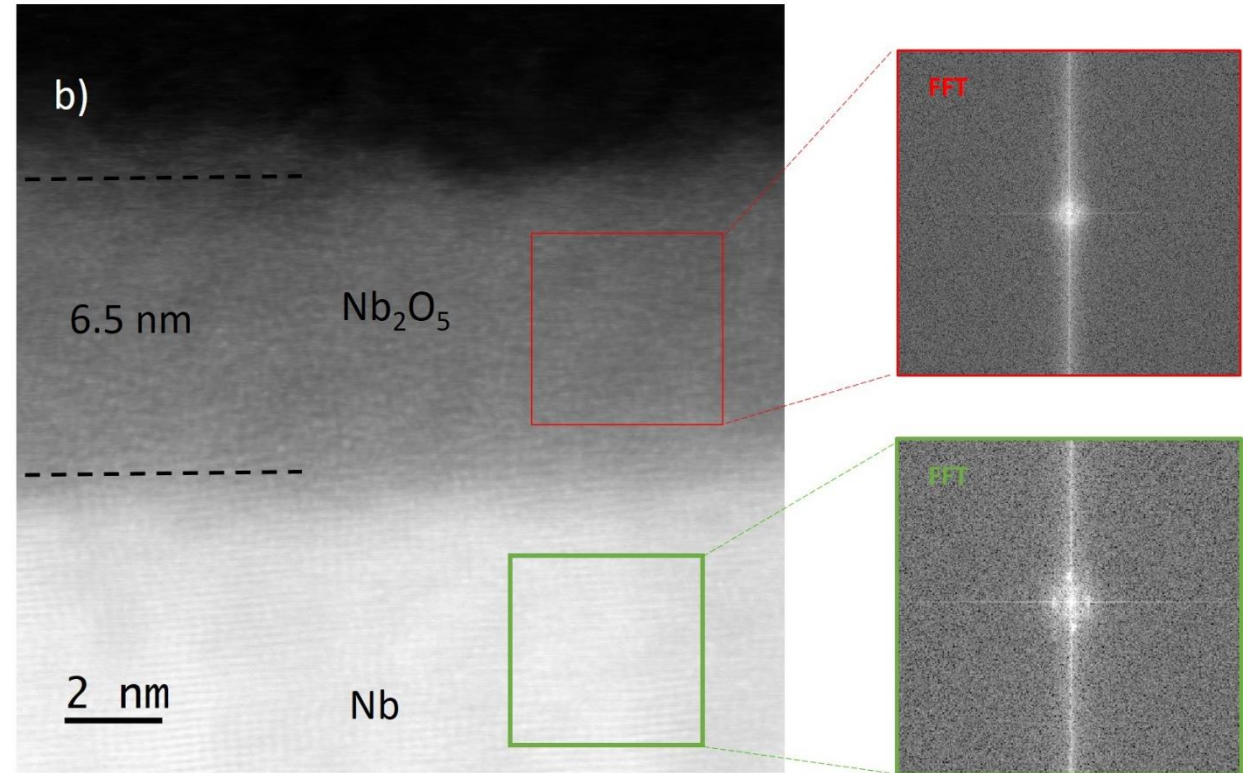
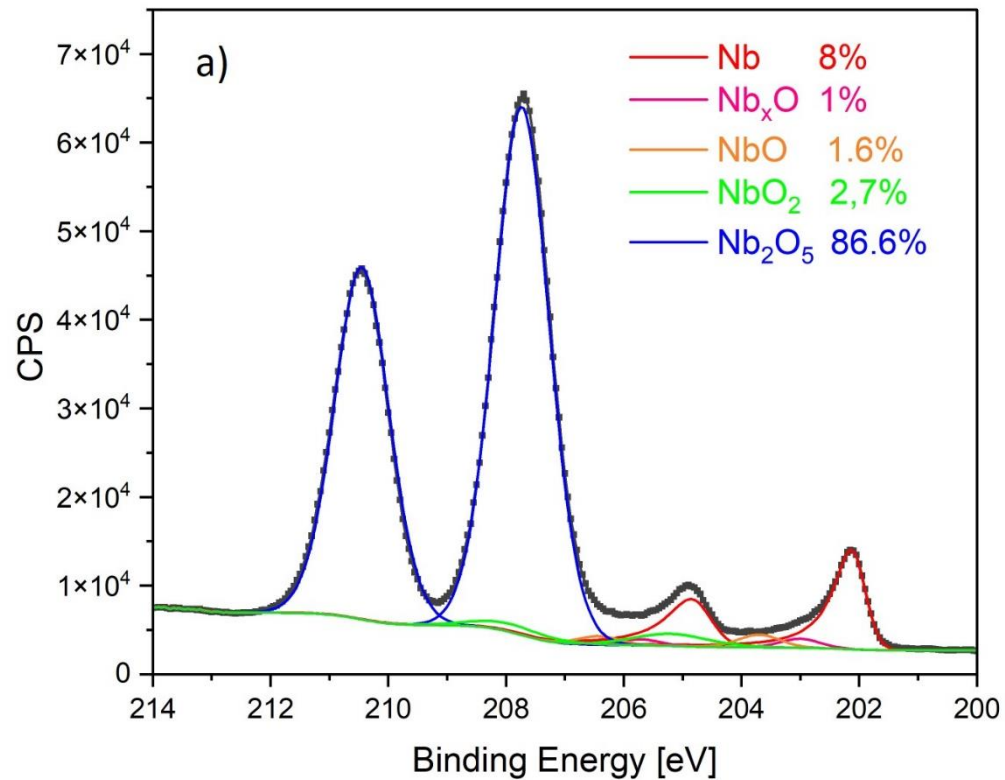
The highest coherence time ever measured on Air exposed Nb: $T_1 = 17$ s at 1.4 K



The highest coherence time ever measured on Air exposed Nb: $T_1 = 17$ s at 1.4 K

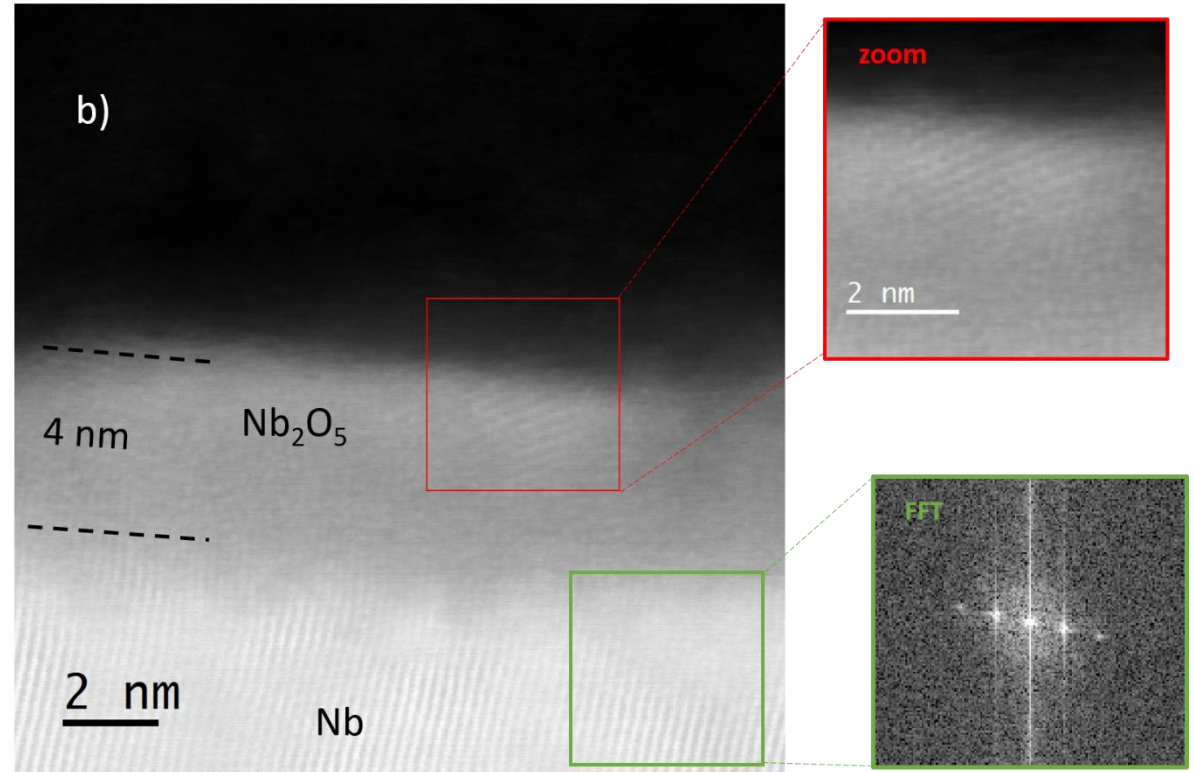
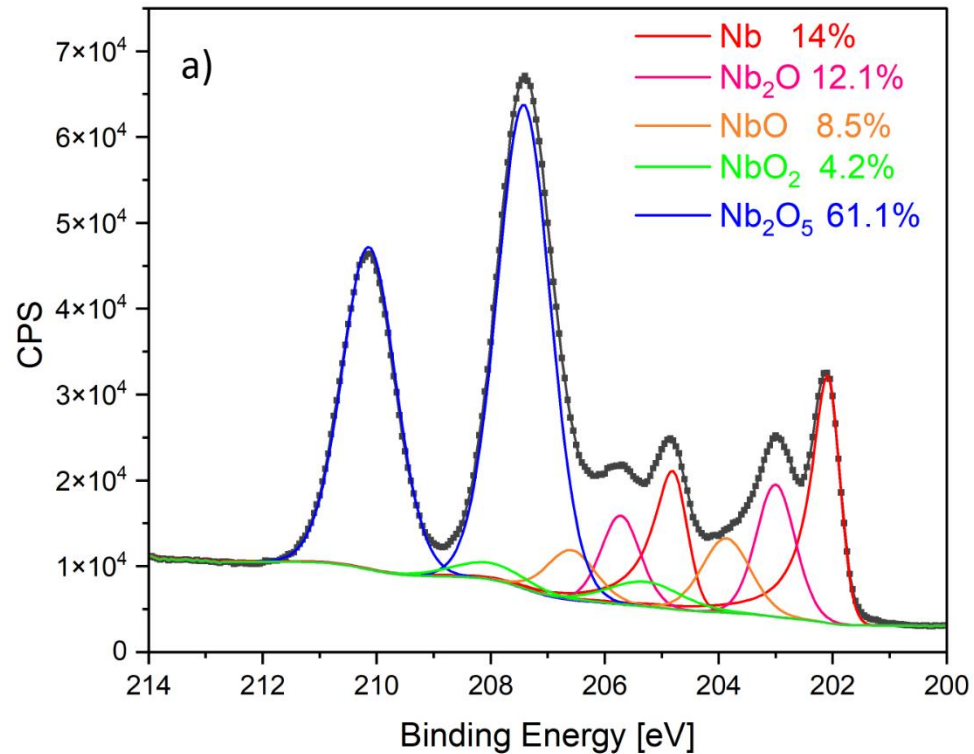


Before the annealing : EP + HPR



- We observe an amorphous Nb oxide of 6.5 nm thickness

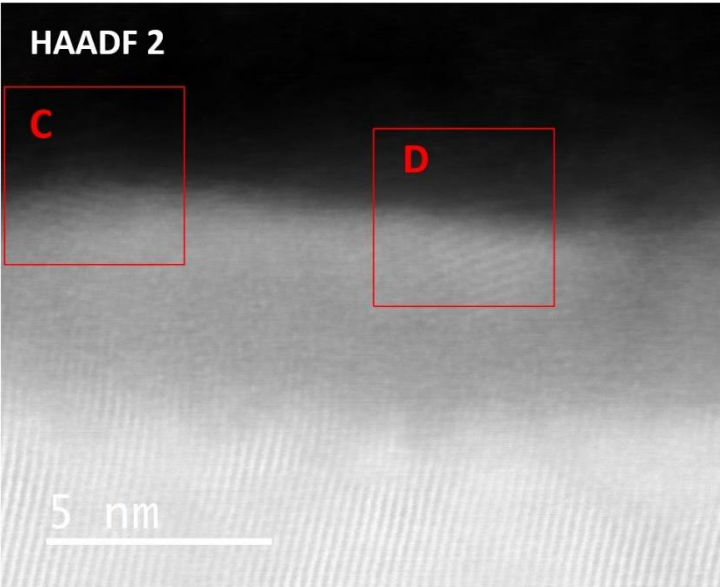
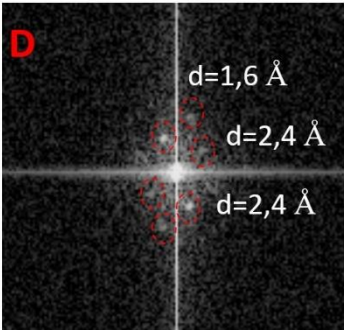
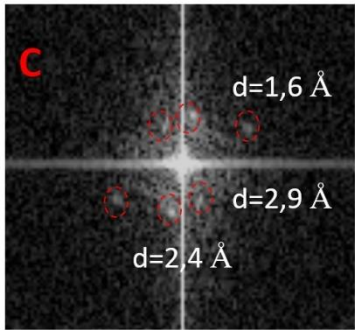
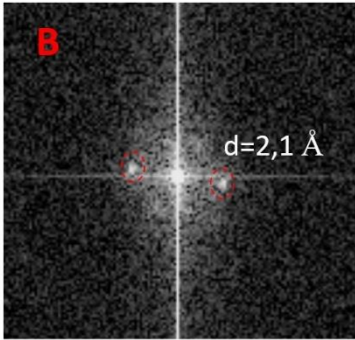
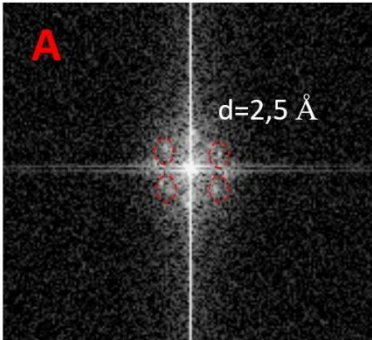
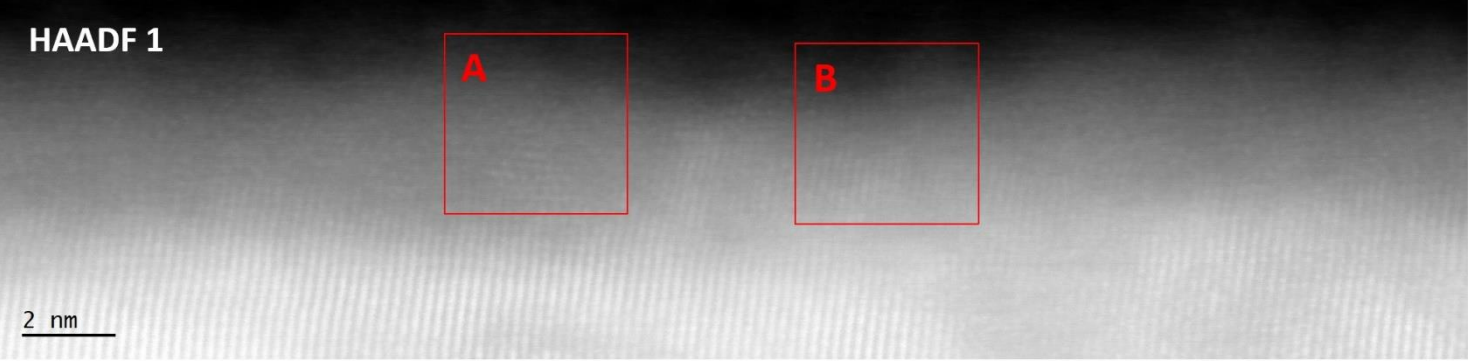
After Annealing: 650°C-10hrs + HPR



- After annealing, the oxide is significantly thinner and shows crystalline regions



After Annealing



Soon to be published

- FFT analysis shows that those crystalline regions are mainly NbO crystallites.
- We conclude that the annealing at 650°C- 10Hrs transforms the Nb₂O₅ native oxide into partially crystalline NbO.
- When re-exposed to air, Nb₂O₅ regrows partially around these crystallites.
- In-situ synchrotron analysis can be done to confirm this mechanism.

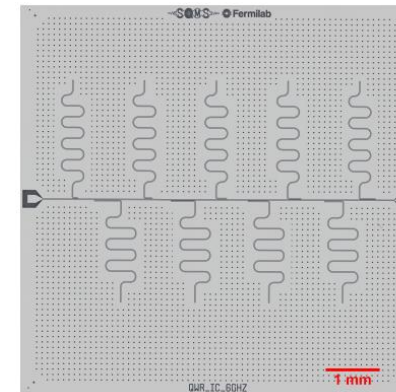
In the future ?

- We are waiting for RF tests on ZrO_2 , Al_2O_3 and Ta_2O_5 cavities.
- We are collaborating with the qubits community in order to test this approach on 2D resonators and Qubits.

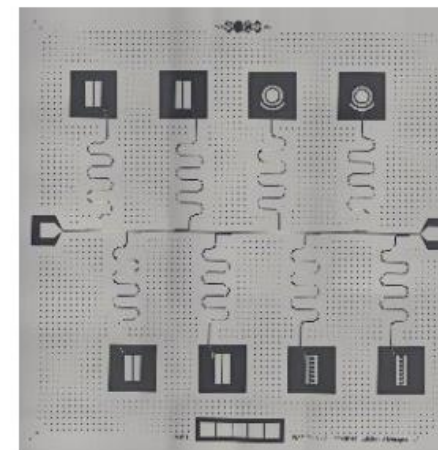
Thank you for your attention !

questions ?

2D resonators



2D resonators + Qubits



SRF cavities
(3D resonators)

References

- [1] Müller, Clemens, Jared H. Cole, and Jürgen Lisenfeld. "Towards understanding two-level-systems in amorphous solids: insights from quantum circuits." *Reports on Progress in Physics* 82.12 (2019): 124501.
- [2] Romanenko, A., and D. I. Schuster. "Understanding quality factor degradation in superconducting niobium cavities at low microwave field amplitudes." *Physical Review Letters* 119.26 (2017): 264801.
- [3] Roy, Tanay, et al. *Qudit-based quantum computing with SRF cavities at Fermilab*. No. FERMILAB-CONF-24-0026-SQMS. Fermi National Accelerator Laboratory (FNAL), Batavia, IL (United States), 2024
- [4] Kalboussi, Yasmine, et al. "Reducing two-level systems dissipations in 3D superconducting niobium resonators by atomic layer deposition and high temperature heat treatment." *Applied Physics Letters* 124.13 (2024).
- [5] Murthy, Akshay, et al. "Detailed Structural and Chemical Analysis of Amorphous Compounds in Superconducting Qubit Systems." (2024).
- [6] Romanenko, A., et al. "Three-dimensional superconducting resonators at $T < 20$ mK with photon lifetimes up to $\tau = 2$ s." *Physical Review Applied* 13.3 (2020): 034032.
- [7] Abdisatarov, B., Bafia, D., Murthy, A., Ereemeev, G., Elsayed-Ali, H. E., Lee, J., ... & Grassellino, A. (2024). Direct Measurement of Microwave Loss in Nb Films for Superconducting Qubits. *arXiv preprint arXiv:2407.08856*.